

Docket No.: 067161-0301

PATENT

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of :  
Toshihiko TANAKA :  
Application No.: Not yet assigned : Group Art Unit: Not yet assigned  
Filed: October 03, 2005 : Examiner: Not yet assigned  
For: SEMICONDUCTOR DEVICE FABRICATION METHOD AND MASK PATTERN  
DATA GENERATION METHOD

## PRELIMINARY AMENDMENT

Mail Stop Amendment  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

Prior to examination of the above-referenced application, please amend the application as follows:

Amendments to the Specification begin on page 2 of this paper.

Amendments to the Claims begin on page 3 of this paper.

Amendments to the Abstract begin on page 9 of this paper.

Remarks / Arguments begin on page 10 of this paper.